

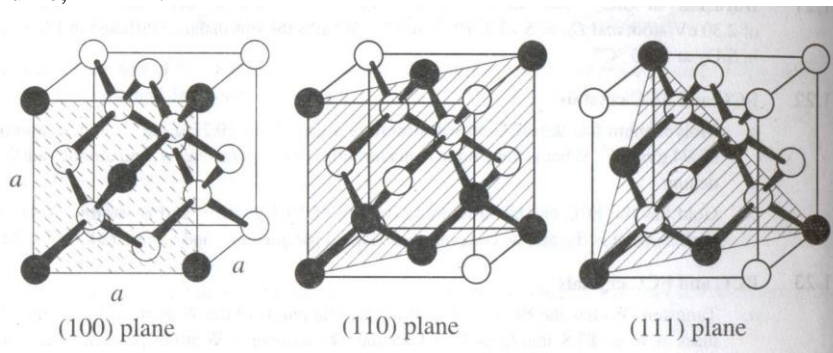
**Indian Institute of Technology Roorkee**  
**Department of Metallurgical and Materials Engineering**  
**MT-105 Electrical and Electronic Materials**

**Assignment 1**

1. Calculate the following:
    - i. **Effective number of atoms** in SC, BCC, FCC, HCP unit cells
    - ii. **Relationship** between the size of the unit cell and atomic diameter in SC, BCC, FCC, HCP unit cells
    - iii. **Packing factors** of BCC, FCC, HCP unit cells
    - iv. **Packing factor** of a diamond cubic crystal structure
    - v. **Coordination numbers** of BCC, FCC, HCP crystal lattice
    - vi. **c/a ratio** for an ideal HCP unit cell
    - vii. **Volume of unit cell** of germanium in cubic meters, the atomic radius of Ge having Diamond Cubic structure being  $1.223 \text{ \AA}$
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2. Show with the help of neat sketches the following:
    - i. **Planes** whose Miller indices are (111), (210), (010),  $(0\bar{1}\bar{1})$ , (002), (130), (212) and  $(3\bar{1}2)$ .
    - ii. **Directions** whose Miller indices are [111], [110],  $[\bar{1}\bar{1}0]$ , [122], [301], [201] and  $[2\bar{3}]$ .
    - iii.  $[\bar{1}\bar{2}10]$ ,  $[01\bar{1}0]$ ,  $[\bar{1}011]$  **directions** and  $(\bar{1}\bar{2}10)$ ,  $(\bar{1}\bar{1}22)$ ,  $(12\bar{3}0)$  **planes** (Miller Bravais Index) in HCP unit cell.  
In a cubic unit cell, the (hkl) &  $[\bar{h}\bar{k}\bar{l}]$  are perpendicular to each other
    - iv. **Miller index** of the direction that is common to both planes (110) and (111) inside the unit cell of a cubic crystal.
    - v. 3 parallel planes of belonging to {111} inside a cubic unit cell (may be touching the UC).
    - vi. 6 direction  $\langle 110 \rangle$  on any one {111}
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3. i. Given the Si lattice parameter  $a=0.543 \text{ nm}$ . Calculate the number of Si atoms per unit volume, in  $\text{nm}^{-3}$ .



- ii. Calculate the number of atoms per  $\text{m}^2$  on the (100), (110), and (111) planes in the Si crystal as shown in above figure. Which plane has the maximum number of atoms per unit area?
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4. i. Why single crystals are used for electronic applications? Explain methods of single crystal growth.
  - ii. How amorphous semiconductors are prepared? Give an example.
  - iii. Explain how the nonstoichiometric, ZnO crystal with excess Zn at the interstitial sites contribute free electron for conduction.
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